DuPont™ EKC922™ Universal Photoresist Remover

Product Description
DuPont™ EKC922™ universal photoresist remover is an organic based photoresist remover formulated to remove positive and negative photoresist and other organic compounds where an ultra clean surface is required.

Advantages
• No phenol or chlorinated solvents
• Extended bath life
• Compatible with III to V compound semiconductors (i.e., GaAs, InP and SiGe)
• Safe to use on semi-cured polyimides
• Compatible with conventional semiconductor materials

Typical Applications
Bulk photoresist removal for:
• MEMS
• Backlap process
• Chrome photomasks
• Metal carriers
• Ink dot removal
• Integrated circuits
• Hybrid device
• III–V compound semiconductors
• Spinner parts
For more information on DuPont™ EKC922™ or other DuPont products, please visit our website.

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